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IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

In re application of : **Confirmation No. 1435**
Takumi KATSURAO et al. : Attorney Docket No. 2005_1625A
Serial No. 10/553,442 : Group Art Unit 1796
Filed February 3, 2006 : Examiner William K Cheung
POROUS FILM OF VINYLIDENE FLUORIDE: Mail Stop: AMENDMENT
RESIN AND METHOD FOR PRODUCING
SAME

AMENDMENT

Commissioner for Patents
P.O. Box 1450
Alexandria, VA 22313-1450

THE COMMISSIONER IS AUTHORIZED
TO CHARGE ANY DEFICIENCY IN THE
FEE FOR THIS PAPER TO DEPOSIT
ACCOUNT NO. 23-0975.

Sir:

Responsive to the Office Action of December 30, 2008, please amend the
above-identified application as follows: